Supporting Information

Sublimable cationic iridium(III) complexes with large steric

hindrance for high-performance organic light-emitting diodes

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Experimental Section

General

¹H-NMR and ¹⁹F-NMR spectra were recorded on a JOEL JNM-ECA600 NMR spectrometer. ESI mass spectrometry was performed with Thermo Electron Corporation Finnigan LTQ. Absorption and photoluminescence (PL) spectra were characterized with an ultraviolet-visible spectrophotometer (Agilent 8453) and a fluorospectrophotometer (HITACHI, F-7000), respectively. Photoluminescence quantum yields (PLQYs) in degassed anhydrous acetonitrile solutions and neat film were measured at the excitation wavelength of 400 nm (Hamamutsu Photonics K. K., C9920-03). The excited state lifetimes were measured by a lifetime and steady state spectrometer (Edinburgh Instruments, FLS 980) with time-correlated single-photon counting technique at the peak emitting wavelength. Cyclic voltammetry was proved in oxygen-free anhydrous solutions on a Princeton Applied Research potentiostat/ galvanostat Model 283 voltammetric analyzer at a scan rate of 100 mV/s with a platinum plate as the working electrode, a silver wire as the pseudo-reference electrode and a platinum wire as the counter electrode. Oxidation potentials were measured in N,N-dimethyl formamide with tetrabutylammonium perchlorate (40 mg mL⁻¹) as the supporting electrolyte, while reduction potentials were performed in acetonitrile with tetrabutylammonium hexafluorophosphate (35 mg mL⁻¹) as the supporting electrolyte. Ferrocene served as the internal standard. Thermal stability was measured by a thermogravimetric analyzer (TA Instruments Q5000) with a heating rate of 10°C min⁻¹ under nitrogen flows.

Device fabrication and evaluation

OLEDs were grown on cleaned, ultraviolet-ozone-treated and indium-tin-oxide-coated glass substrates, with a sheet resistance of about 20 Ω per sq. Each functional layer was fabricated thereon successively by vacuum evaporation deposition under a low pressure below 5×10⁻⁴ Pa. Each device shows an active area of 3.0×3.0 mm². Current density-luminance-voltage (J-L-V) characteristics were collected with Keithley 4200 semiconductor system, while electroluminescence (EL) spectra were recorded by a Photo Research PR705 spectrophotometer. Device measurements were carried out at room temperature in the ambient air without further encapsulations.



Scheme S1 Synthetic routes of complexes 1.



Fig. S1 (a) Absorption spectra, (b) PL spectra in oxygen-free acetonitrile solutions, (c) PL spectra in spin-coated neat films, and (d) PL spectra at 77 K. (e) Cyclic voltammogram, and (f) TGA under nitrogen-flow conditions of complexes **5** and **6**.



Fig. S2 Excited state lifetimes of complex 1 (a) in neat films at room temperature and (b) in acetonitrile glass at 77 K.



Fig. S3 Excited state lifetimes of complex 2 (a) in neat films at room temperature and (b) in acetonitrile glass at 77 K.



Fig. S4 Excited state lifetimes of complex **3** (a) in neat films at room temperature and (b) in acetonitrile glass at 77 K.



Fig. S5 Excited state lifetimes of complex 4 (a) in neat films at room temperature and (b) in acetonitrile glass at 77 K.



Fig. S6 Excited state lifetimes of complex 5 (a) in neat films at room temperature and (b) in acetonitrile glass at 77 K.



Fig. S7 Excited state lifetimes of complex 6 (a) in neat films at room temperature and (b) in acetonitrile glass at 77 K.



Fig. S8 Characteristics of the OLEDs based on complex **3** in the structure of ITO/ HATCN (5 nm)/ NPB (40 nm)/ TCTA (10 nm)/ DIC-TRZ: x% complex **3** (12 nm)/ BPBiPA (50 nm)/ LiF (1 nm)/ Al (150 nm) at varying dopant concentrations. (a) Current efficiency-luminance curves, (b) EL spectra and (c) Current density-voltage, (d) Luminance-voltage.



Fig. S9 Characteristics of the OLEDs based on complex **4** in the structure of ITO/ HATCN (5 nm)/ NPB (40 nm)/ TCTA (10 nm)/ DIC-TRZ: x% complex **4** (12 nm)/ BPBiPA (50 nm)/ LiF (1 nm)/ Al (150 nm) at varying dopant concentrations. (a) Current efficiency-luminance curves, (b) EL spectra and (c) Current density-voltage, (d) Luminance-voltage.



Fig. S10 Characteristics of the OLEDs based on complex **5** in the structure of ITO/ HATCN (5 nm)/ NPB (40 nm)/ TCTA (10 nm)/ DIC-TRZ: x% complex **5** (12 nm)/ BPBiPA (50 nm)/ LiF (1 nm)/ Al (150 nm) at varying dopant concentrations. (a) Current efficiency-luminance curves, (b) EL spectra and (c) Current density-voltage, (d) Luminance-voltage.



Fig. S11 Characteristics of the OLEDs based on complex **6** in the structure of ITO/ HATCN (5 nm)/ NPB (40 nm)/ TCTA (10 nm)/ DIC-TRZ: x% complex **6** (12 nm)/ BPBiPA (50 nm)/ LiF (1 nm)/ Al (150 nm) at varying dopant concentrations. (a) Current efficiency-luminance curves, (b) EL spectra and (c) Current density-voltage, (d) Luminance-voltage.

| | Ratio | V [a] | Max CE ^[b] | $CE^{[b]}$ at 10 ³ cd m ⁻ | CE ^[b] at 10 ⁴ cd m ⁻ | Max | Max PE[d] | Max I[e] | ۲ [f] | CIF ^[g] |
|---|-------|-----------|---|---|--|--------|---------------|--|---------------|----------------------------|
| | [0/] | [V] | $\left[\operatorname{cd} \Lambda^{-1} \right]$ | | | EOE[c] | $[1m W^{-1}]$ | $\left[\operatorname{ad} \mathbf{m}^{-2} \right]$ | [nm] | (\mathbf{r}, \mathbf{u}) |
| | [/0] | [•] | | [ad A-1] | [ad A-1] | EQE: 3 | | | [11111] | (x, y) |
| | | | | | | [70] | | | | (0. 10. 0. 7.1) |
| 1 | 1.5 | 2.5 | 8.5 | 7.0 | 1.8 | 3.0 | 7.1 | 13.0×10^{3} | 560, 592(sh) | (0.48,0.51) |
| 2 | 1.3 | 2.5 | 8.5 | 8.2 | 3.6 | 3.1 | 6.5 | 16.3×10 ³ | 560, 592 (sh) | (0.49, 0.50) |
| 3 | 0.8 | 2.3 | 23.0 | 21.1 | 13.8 | 8.3 | 20.7 | >27.3×10 ³ | 558, 591 (sh) | (0.49, 0.50) |
| | 1.1 | 2.2 | 27.5 | 24.6 | 20.3 | 10.1 | 24.3 | $>27.3 \times 10^{3}$ | 560, 591 (sh) | (0.49, 0.50) |
| | 1.5 | 2.2 | 32.4 | 30.0 | 24.5 | 11.9 | 28.3 | >27. 3×10 ³ | 558, 591 (sh) | (0.49, 0.50) |
| | 1.9 | 2.2 | 27.4 | 25.0 | 21.3 | 10.2 | 23.5 | >27. 3×10 ³ | 560, 593 (sh) | (0.50, 0.49) |
| 4 | 0.6 | 2.4 | 39.8 | 38.6 | 25.2 | 11.2 | 38.6 | $>27.3 \times 10^{3}$ | 560, 592 (sh) | (0.50, 0.49) |
| | 0.9 | 2.4 | 41.8 | 39.0 | 25.4 | 14.7 | 40.3 | >27. 3×10 ³ | 560, 592 (sh) | (0.49, 0.49) |
| | 1.2 | 2.4 | 36.5 | 35.6 | 22.0 | 13.9 | 36.9 | >27. 3×10 ³ | 560, 592 (sh) | (0.49, 0.50) |
| | 1.5 | 2.5 | 37.1 | 31.9 | 18.8 | 13.3 | 34.4 | $>27.3 \times 10^{3}$ | 560, 592 (sh) | (0.50, 0.49) |
| 5 | 1.4 | 2.4 | 32.5 | 29.0 | 20.1 | 11.4 | 33.8 | >27.0×10 ³ | 558, 591 (sh) | (0.48, 0.51) |
| | 1.7 | 2.4 | 32.9 | 30.5 | 21.9 | 12.0 | 34.7 | >27.0×10 ³ | 558, 591 (sh) | (0.48, 0.51) |
| | 1.9 | 2.4 | 31.2 | 30.8 | 22.7 | 10.9 | 32.3 | $>27.0 \times 10^{3}$ | 558, 591 (sh) | (0.48, 0.51) |
| | 2.0 | 2.4 | 29.4 | 29.1 | 21.5 | 10.2 | 29.5 | >27.0×10 ³ | 558, 591 (sh) | (0.48, 0.51) |
| 6 | 0.9 | 2.1 | 30.8 | 29.9 | 20.6 | 11.7 | 31.6 | >27. 3×10 ³ | 560, 596 (sh) | (0.50, 0.49) |
| | 1.1 | 2.2 | 37.8 | 33.4 | 24.3 | 14.1 | 40.9 | >27. 3×10 ³ | 560, 596 (sh) | (0.50, 0.49) |
| | 1.3 | 2.2 | 38.1 | 33.9 | 25.8 | 14.3 | 41.0 | >27. 3×10 ³ | 560, 596 (sh) | (0.50, 0.49) |
| | 1.5 | 2.2 | 36.0 | 33.7 | 26.1 | 13.5 | 39.0 | >27. 3×10 ³ | 560, 596 (sh) | (0.50, 0.50) |

Table S1 Device characteristics of yellow-emitting OLEDs based on complexes 1-6.

[a] V_{on} , turn-on voltage. [b] CE, current efficiency. [c] EQE, external quantum efficiency. [d] PE, power efficiency. [e] L, luminance. [f] λ_{EL} , EL wavelength, sh denotes the shoulder peak. [g]

CIE, Commission Internationale de l'Elairage.